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DISCLOSURE STATEMENT					Filing Date	Gr	oup Art: 3763
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•	LIST OF PATENTS AND PUBLICATIONS FOR	Applicant: Ting Tina Ye et al.		
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		April 20, 2001	3763	
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ÅA	mo	5,961,511	10/05/1999	Mortier et al.	
AB	L	09/430,327		Centell et al.	10/29/1999
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